

**Amendments to the Claims are as follows:**

1. (Currently Amended) A functional multilayer film comprising ~~obtained by fixing a plurality of fine metallic bodies to a matrix made of a dielectric substance,~~

~~wherein the~~ a matrix is ~~obtained by~~comprising laminating metal-arranged thin films, each metal-arranged thin film comprising a dielectric thin film having a predetermined thickness and ~~the~~ a plurality of fine metallic bodies arranged on the dielectric thin film, ~~and~~

~~wherein a plurality of recesses is regularly formed on the~~ a surface of ~~the~~ each dielectric thin film, and the fine metallic bodies are arranged in ~~the~~ lower parts of the recesses.

2. (Currently Amended) A functional multilayer film according to Claim 1,

wherein the dielectric thin film and the fine metallic bodies are made of different materials in every metal-arranged thin film or in every region including a plurality of the metal-arranged thin films.

3. (Currently Amended) A method for manufacturing a functional multilayer film comprising ~~the steps of:~~

~~forming a dielectric thin film so as to have a plurality of recesses regularly arranged on the~~ a surface of a dielectric thin film; thereof,

~~forming a metal-arranged thin film by forming a metallic thin film on the dielectric thin film, and performing a heat treatment to~~ on the metallic thin film ~~so as for~~ such that metal of the metallic thin film ~~to flow~~ into the lower parts of the recesses of the dielectric thin film to form fine metallic bodies, ~~and~~

~~forming a matrix by laminating a plurality of the metal-arranged thin films, each comprising the dielectric thin film and the fine metallic bodies.~~